

## 2.c IPR and Patents: Granted, Filed, Licensed (IPR) – 15 Marks

Proposed Marks distribution –

Granted : 6 Marks,

Filed : 3 Marks,

Licensed : 6 Marks

IPR will be broadly based on registered copyrights, designs and patents over the last three (3) years.

Assessment method will be identical for both categories. However, the indicated percentile will be calculated for the two categories separately.

$$\mathbf{IPR = PF + PG + PL}$$

Assessment of IPR on patents (including copyrights and designs) filed:

$$\mathbf{PF = 3 \times \text{Percentile parameter (expressed as a fraction) on the basis of (PF/F)}}$$

Here,

**PF** is the number of patents, copyrights, designs filed. **F** is the number of regular faculty members.

Assessment M etric for IPR on patents (including copyrights and designs) granted:

$$\mathbf{PG = 6 \times \text{Percentile parameter (expressed as a fraction) on the basis of (PG/F)}}$$

Here,

**PG** is the number of patents, copyrights, designs granted/registered. **F** is the number of regular faculty members.

Assessment Metric for IPR and Patents Licensed:

**$PL = 2 \times I(P) + 4 \times \text{Percentile parameter (expressed as a fraction)}$**   
**based on  $(EP/F)$**

Here,

**EP** is the total earnings from patents etc. over the last three (3) years.

**$I(P) = 1$** , if at least one patent was licensed in the previous three (3) years

or at least one technology transferred during this period;

Otherwise,

**$I(P) = 0$**

**F** is the average number of regular faculty over this period.

**Data Collection:**

To be made available by the concerned institutes On-line.

**Data Verification:**

By Ranking Agency on a Random Sample Basis.